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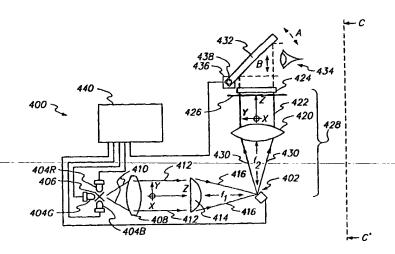
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(54) Title: METHOD AND APPARATUS FOR MODULATING AN INCIDENT LIGHT BEAM FOR FORMING A TWO-DIMENSIONAL IMAGE



(57) Abstract

An apparatus and method for modulating an incident light beam for forming a two-dimensional projection image. The apparatus includes a plurality of elongated elements each having a reflective surface. These are suspended parallel to each other above a substrate with their respective ends supported, forming a column of adjacent reflecting surfaces grouped according to display elements. Alternate ones of each group are deformable by applying a voltage with respect to the substrate. An approximately flat center section of each deformed element is substantially parallel to and a predetermined distance from a center section of each undeformed element. A light beam incident to the column of adjacent reflecting surfaces is reflected from a group of elongated elements when the alternate ones are undeformed and diffracted when the alternate ones are deformed. A distance of movement is controlled or a ratio of between reflection and diffraction periods determines a display intensity for the corresponding display element.

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METHOD AND APPARATUS FOR MODULATING AN INCIDENT LIGHT BEAM FOR FORMING A TWO-DIMENSIONAL IMAGE

5 Field of the Invention:

The invention relates to a method and apparatus for modulating a light beam for forming a two-dimensional image. More particularly, the invention relates to a columnar diffraction grating for performing such modulation.

10 Background of the Invention:

Many applications exist for **devices** which modulate a light beam, e.g. by altering the amplitude, frequency or phase of the light. An example of such a device is a reflective deformable grating light modulator 10, as illustrated in Fig. 1. This modulator 10 was proposed by Bloom et al., in U.S. Patent No. 5,311,360. The modulator 10 includes a plurality of equally spaced apart, deformable reflective ribbons 18 which are suspended above a substrate 16 having reflective surface portions. An insulating layer 11 is deposited on the silicon substrate 16. This is followed by the deposition of a sacrificial silicon dioxide film 12 and a low-stress silicon nitride film 14. The nitride film 14 is patterned to form the ribbons 18 and portions of the silicon dioxide layer 12 are etched such that the ribbons 18 are held by a nitride frame 20 on an oxide spacer layer 12. For modulating light having a single wavelength λ_0 , the modulator is designed such that the thickness of the ribbons 18 and the thickness of the oxide spacer 12 both equal $\lambda_0/4$.

The grating amplitude of this modulator 10, defined as the perpendicular distance, d, between the reflective surfaces 22 on the ribbons 18 and the reflective surfaces of the substrate 16, is controlled by applying voltage between the ribbons 18 (the reflective surface 22 of the ribbons 16 serves as a first electrode) and the substrate 16 (a conductive film 24 beneath the substrate 16 serves as a second electrode). In its undeformed state, with no voltage applied, the grating amplitude equals $\lambda_0/2$ and the total path length difference between light reflected from the ribbons and the substrate equals λ_0 , resulting in these reflections adding in phase. Thus, in the undeformed state, the modulator 10 reflects light as a flat mirror. The undeformed state is illustrated in Fig. 2 with incident and

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reflected light indicated as 26.

When an appropriate voltage is applied between the ribbons 18 and the substrate 16, an electrostatic force deforms the ribbons 18 into a down position in contact with the surface of the substrate 16. In the down position, the grating amplitude is changed to equal $\lambda_0/4$. The total path length difference is one-half the wavelength, resulting in the reflections from the surface of the deformed ribbons 18 and the reflections from the substrate 16 interfering destructively. As a result of this interference the modulator diffracts the incident light 26. The deformed state is illustrated in Fig. 3 with the diffracted light in the +/-1 diffraction modes (D_{+1}, D_{-1}) indicated as 28 and 30, respectively.

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Adhesion between the ribbons 18 and the substrate 16 during wet processing utilized to create the space below the ribbons 18 and during operation of the modulator 10 has been found to be a problem in these devices. Numerous techniques to reduce adhesion have been proposed, including: freeze-drying, dry etching of a photoresist-acetone sacrificial layer, OTS monolayer treatments, use of stiffer ribbons by using shorter ribbons and/or tenser nitride films, roughening or corrugating one or both of the surfaces, forming inverted rails on the underneath of the ribbons, and changing the chemical nature of the surfaces. Sandejas et al. in "Surface Microfabrication of Deformable Grating Light Valves for High Resolution Displays" and Apte et al. in "Grating Light Valves for High Resolution Displays", Solid State Sensors and Actuators Workshop, Hilton Head Island, SC (June 1994), have demonstrated that such adhesion may be prevented by reducing the area of contact by forming inverted rails on the underneath of the bridges and by using rough polysilicon films, respectively.

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Furthermore, as Apte et al. recognize, a feature of the mechanical operation of the modulator 10 is hysteresis in the deformation of the ribbons 18 as a function of applied voltage. The theorized reason for the hysteresis is that the electrostatic attractive force between the ribbons 18 and the substrate 16 is a non-linear function of the amount of deformation, while the restoring force caused by stiffness and tension of the ribbons 18 is a substantially linear function. Fig. 4 illustrates a simulated hysteresis characteristic where the light output (an indirect indicator of the amount of deformation of the ribbons 18) is shown on the vertical axis and the voltage between the ribbons 18 and the substrate 16 is shown on the horizontal axis. Thus, when the ribbons 18 are deformed into the down

position in contact with the substrate 16, they latch in place, requiring a smaller holding voltage than the original applied voltage.

Bloom et al., in U.S. Patent No. 5,311,360 teach that this latching feature is desirable as it gives the modulator 10 the advantages of active matrix design without the need for active components. In addition, Bloom et al. teach that this latching feature is also desirable in low power applications where efficient use of available power is very important. Recognizing the adhesion problem, however, Bloom et al., teach adding small ridges below the ribbons 18 to reduce the contact area and thereby reduce the adhesion problem. Because the substrate of the modulator 10 is used as an optical surface, however, the manufacturing processes for adding small ridges to the surface is complicated by the requirements that the reflecting portions of the substrate 16 be smooth with high reflectivity and be in a plane parallel to the ribbons 18.

Conventional displays are formed in two dimensional arrays of pixels. The discrete image formed by each of the myriad of pixels are integrated by the eye of the user to form a composite of the pixels representing an overall image. Unfortunately, the cost of such a display system increases because as each pixel is replicated to form the entire array the cost of making each pixel is similarly replicated. Examples of such pixellated displays are televisions and computer monitors. The pixels for each can be formed of LCD devices, or by a CRT.

Therefore, what is needed is a diffraction grating light valve in which adhesion between reflective elements and a substrate is reduced or eliminated without resorting to complicated surface treatments required for reducing such adhesion.

What is also needed is a display that lowers the cost of manufacture by reducing the number of pixels required to build the system without lowering the image quality.

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Summary of the Invention:

The invention is a diffraction grating light valve (GLV) and method of use thereof for modulating an incident light beam for forming a two-dimensional image. The diffraction grating light valve includes a plurality of elongated elements each of which have a reflective surface. The elongated elements are suspended substantially parallel to each other above a substrate with their respective ends supported and substantially aligned so as

to form a column of adjacent reflecting surfaces (GLV array). The elongated elements are grouped according to display elements. Alternate ones of each group are deformable by a applying a voltage with respect to the substrate. An approximately flat center portion of each deformed element is substantially parallel to and a predetermined distance from a center portion of each undeformed element. The predetermined distance is selected to be approximately one-third to one-fourth of the distance between the undeformed reflective surfaces and the substrate such that deformed elongated elements do not contact the surface of the substrate. Avoiding contact with the substrate prevents the elongated elements from adhering to the substrate. In addition, limiting the predetermined distance avoids hysteresis in deforming the elongated elements.

A light beam incident to the column of adjacent reflecting surfaces is reflected from a group of elongated elements when the alternate ones of the group are undeformed. The light beam is diffracted by a group of elongated elements when alternate ones of the group are deformed. A ratio of between reflection and diffraction for a group during a time period determines a display intensity for the corresponding display element. The light beam is alternately red, green and blue during successive periods. In an alternate embodiment, the light beam is white light and widths of the elongated elements for each display element are selected to diffract red, green or blue wavelengths at an appropriate diffraction angle. An appropriate intensity and color for each display element is formed during respective periods according to the image to be represented by the respective display element.

Light diffracted from the column of reflecting surfaces is collected by a lens. At the exit pupil of the lens, the light is columnar and representative of a column of the image to be displayed. A light shield having a slit of predetermined width over the length of the column is positioned at the pupil of the second lens such that only a selected portion of the light passes through the slit. This arrangement of the shield prevents light collected by the first lens other than light diffracted from the approximately flat center portions of the elongated elements from passing through the slit. In an alternate embodiment, a fixed reflecting surface is placed over the ends of the elongated elements to prevent light from being diffracted other than from the approximately flat center portion of each elongated element. A pivotable reflective surface (scanning mirror) is positioned opposite the light

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shield from the lens to reflect the light passing through the slit into an eyepiece or onto a display screen. The reflective surface pivots back and forth, in synchronism with the column of display elements modulating the light, to represent columns of the display image. Accordingly, a two-dimensional color image is swept into the eyepiece or onto the display screen. The pivotable scanning mirror can be replace with other types of mirror arrangements such as a rotating faceted polygon mirror.

Brief Description of the Drawings:

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- Fig. 1 illustrates a prior art reflective deformable grating light modulator.
- Fig. 2 illustrates the prior art reflective deformable grating light modulator in an undeformed state, reflecting incident light.
 - Fig. 3 illustrates the prior art reflective deformable grating light modulator in a deformed state, diffracting incident light.
 - Fig. 4 illustrates a hysteresis curve for the prior art reflective deformable grating light modulator.
 - Figs. 5-6 and 8 illustrate side sectional views of a process sequence for manufacturing a columnar diffraction grating light valve (GLV) according to the present invention.
 - Fig. 7 illustrates a top view of a step of the process sequence for manufacturing a columnar diffraction grating light valve according to the present invention.
 - Fig. 9 illustrates a side sectional view of the columnar diffraction grating light valve according to the present invention.
 - Fig. 10 illustrates a top view of a portion of the GLV including six elongated elements corresponding to a single display element.
 - Fig. 11 illustrates a front sectional view of a display element of the GLV with the six elongated elements undeformed, reflecting incident light.
 - Fig. 12 illustrates a side sectional view of a deformed elongated element of the GLV according to the present invention.
- Fig. 13 illustrates a front sectional view of the display element of the GLV with alternate ones of the six elongated elements deformed, diffracting incident light.
 - Fig. 14 illustrates top view of an optical display system utilizing the GLV.

Fig. 15 illustrates a side view of the optical display system illustrated in Fig. 14 taken along the line C-C'.

Fig. 16 illustrates a side cross sectional view of an eyepiece arrangement for use with the optical display system illustrated in Fig. 14 including an exit pupil.

Fig. 17 illustrates a side cross sectional view of a display screen arrangement for use with the optical display system illustrated in Fig. 14 including the exit pupil.

Fig. 18 illustrates an alternate embodiment of the present invention for avoiding display of light diffracted from other than an approximately flat center portion of the elongated elements.

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Detailed Description of a Preferred Embodiment:

Figs. 5-6 and 8 illustrate side sectional views of a process sequence for manufacturing a columnar diffraction grating light valve (GLV) according to the present invention. Referring to Fig. 5, an insulating layer is formed on a silicon substrate 100. Preferably, the insulating layer is a composite layer including a field oxide layer 102 formed by thermal oxidation and a thin layer of silicon nitride 104 formed over the field oxide layer 104. Then, a conducting layer 106 is formed over the nitride layer 104. Preferably, the conducting layer 106 is a refractory metal, such as tungsten, molybednum, titanium-tungsten or tantalum or alternatively conductive Poly-silicon or a diffused conductor. The conducting layer 106 serves as a lower electrode for applying bias to selected ones of elongated elements of the GLV. In an alternate embodiment, the conducting layer 106 is formed on a lower surface of the substrate 100.

Next, a sacrificial layer 108 is formed over the conducting layer 106. The sacrificial layer 108 must be able to be selectively etched with respect to the conducting layer 106. Preferably, the sacrificial layer 108 is a layer of Poly-silicon which is etched with a dry etch of xenon diflouride. Alternatively, the sacrificial layer can be a layer of doped glass, such as boro-phospho-silicate glass or phoso-silicate glass. The thickness at which the sacrificial layer 108 is applied determines a distance between the conducting layer 106 and elongated elements to be formed over the sacrificial layer 108. As will be explained herein, the thickness of the sacrificial layer 108 departs significantly from prior light modulators in that the sacrificial layer 108 is substantially thicker. In the preferred

embodiment, the thickness of the sacrificial layer 108 is approximately equal to the expected wavelength of incident light. For example, if the expected wavelength is in the visible range (approximately 450-760 nm), the thickness of the sacrificial layer 108 is also within this approximate range. If the expected wavelength is in the ultraviolet range (approximately 200-450 nm) the thickness of the sacrificial layer 108 is also within this approximate range. If the expected wavelength is in the infrared range (approximately 760-2000 nm) the thickness of the sacrificial layer 108 is also within this approximate range.

Referring to Fig. 6, the conducting layer 106 and the sacrificial layer 108 are photo-lithographically masked by known techniques and then etched sequentially by appropriate dry or wet etch chemistries, forming a pair of post holes 110 for each elongated element of the GLV. Preferably, the post holes 110 are formed at distance of approximately 75 microns from each other, though another distance can be utilized. For illustration purposes, the apparent thicknesses of the layers 102-108 are exaggerated relative the distance between the post holes 110.

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Fig. 7 illustrates a top view of the GLV after the post holes 110 have been etched as described above. For illustration purposes, Fig. 7 illustrates a column of six pairs of post holes 110, each pair corresponding to an elongated element of the GLV. In the preferred embodiment, the GLV includes more pairs of post holes 110. For example, 1920 pairs of post holes 110 can be utilized corresponding to 1920 elongated elements arranged in a columnar array.

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Referring to Fig. 8, a layer of resilient material 112 is formed over the sacrificial layer 108 and post holes 110, partially or completely filling the post holes 110. Preferably, the resilient material 112 is layer of silicon nitride deposited to a thickness and residual stress defined by a spring force necessary to return each elongated element to an up state after a sufficient opposite polarity bias is applied to cancel electrostatic force induced by a bias applied to place the elongated element in a down state. Next, a reflective layer 114 is deposited over the resilient layer 112. The reflective layer 114 provides a reflective surface for each elongated element of the GLV and serves as an upper electrode for applying bias to selected ones of the elongated elements of the GLV. Preferably, the reflective layer 114 is sputtered aluminum.

Finally, a photoresist layer 118 is applied as a mask for selectively patterning the reflective layer 114 and the resilient layer 112 for forming the elongated elements. In addition, the sacrificial layer 108 is etched, leaving an air space beneath the elongated elements.

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Fig. 9 illustrates a side sectional view of an elongated element 200 of the GLV in an undeformed state. Note that in Fig. 9, the sacrificial layer 108 (Figs. 5-6 and 8) beneath the elongated element 200 is replaced by an air space 202. Thus, the elongated element 200 is suspended by its ends above the surface of the substrate (including its constituent layers). In addition, the photoresist layer 118 (Fig. 8) has been removed.

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Fig. 10 illustrates a top view of a portion of the GLV including six elongated elements 200. Note that the elongated elements 200 have equal widths and are arranged parallel to each other. The elongated elements 200 are also separated from each other by a small space, thus, allowing each elongated element 200 to be selectively deformed with respect to the others. The six elongated elements 200 illustrated in Fig. 10 preferably correspond to a single display element 300. Thus, the column of 1920 elongated elements corresponds to a GLV array having 320 display elements arranged in a column. It will be apparent that the number of display elements will affect a resulting display resolution and that a different number can be selected. In addition, each display element 300 can have a different number of elongated elements 200. For example, a group of two, four, eight, ten or twelve elongated elements 200 can correspond to a single display element 300. It is possible that even more elongated elements could be used to form a single display element 300. It is also possible that an odd number of elongated elements 200 could be used for a single display element 300.

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Fig. 11 illustrates a front sectional view of the display element 300 with the elongated elements 200 undeformed. The section illustrated in Fig. 11 is taken along the line A-A' illustrated in Fig. 9. The undeformed state is achieved by equalizing a bias on each elongated element 200 with respect to the conductive layer 106. Note that because the reflective surfaces of the elongated elements 200 are substantially co-planar, light incident to the elongated elements 200 is reflected.

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Fig. 12 illustrates a side sectional view of a deformed elongated element 200 of the GLV. Fig. 12 illustrates that in the deformed state, the elongated element 200 remains

suspended in that it does not come into contact with the surface of the substrate layers beneath the elongated element 200. This is in contrast to the prior modulator of Figs. 1-3. By avoiding contact between the elongated element 200 and surface of the substrate, the problem of adhesion associated with the prior modulator is avoided. Note, however, that in the deformed state, the elongated element 200 tends to sag. This is because the electrostatic force pulling the elongated element 200 toward the substrate is distributed evenly along its length, perpendicularly to the length, whereas the tension of the elongated elements 200 is along the length of the elongated element 200. Thus, its reflective surface is curvilinear, rather than flat. Note, however, that for illustration purposes, in Fig. 12, the degree of sagging of the elongated element 200 is exaggerated relative to its length.

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It has been found, however, that a center portion 202 (Fig. 12) of the elongated elements 200 remains approximately flat, such that a contrast ratio resulting from obtaining light diffracted only by the center portion 202 of each elongated element 200 is satisfactory. In practice it has been found that the approximately flat center portion 202 is approximately one-third the length between the post holes 110. Therefore, when the distance between post holes is 75 microns, the approximately flat center portion 202 is approximately 25 microns in length.

Fig. 13 illustrates a front sectional view of the display element 300 with alternate ones of the elongated elements 200 deformed. The section illustrated in Fig. 13 is taken along the line B-B' illustrated in Fig. 12. The elongated ribbons 200 that are not moved substantially are held in a desired location by applying a bias voltage thereto. The deformed state in the elongated ribbons 200 that move is achieved by applying an appropriate drive voltage on the alternate ones of the elongated elements 200 with respect to the conductive layer 106. The perpendicular distance d₁ is approximately constant over the approximately flat center portion 202 (Fig. 12) and, thus, defines a grating amplitude for the GLV. The grating amplitude d₁ can be adjusted by adjusting the drive voltage on the driven elements elongated 200. This makes possible fine tuning of the GLV for an optimum contrast ratio.

For appropriately diffracting incident light having a single wavelength (λ_1) , it is preferred that the GLV have a grating amplitude d_1 equal to one fourth of the wavelength of the incident light $(\lambda_1/4)$ for a maximum contrast ratio in the displayed image. It will be

apparent, however, that the grating amplitude d_1 need only result in a round trip distance equal to one-half the wavelength λ_1 plus a whole number of wavelengths λ_1 (i.e. $d_1 = \lambda_1/4$, 3 $\lambda_1/4$, 5 $\lambda_1/4$,..., $N\lambda_1/2 + \lambda_1/4$).

Referring to Fig. 13, it can be seen that the lower surface of each deformed elongated element 200 is separated from the surface of the substrate by a distance d_2 . Thus, the elongated elements 200 do not make contact with the substrate during operation of the GLV. This avoids the problem in prior modulators of adhesion between the reflective ribbons and the substrate. This distance d_2 is preferably selected to be approximately two to the three times the distance d_1 . Accordingly, in the deformed state, the elongated elements 200 travel approximately one-fourth to one-third of the distance d_2 to the substrate. The distance d_2 is determined by the thickness of the sacrificial layer 108 (Figs. 5-6 and 8) plus the distance d_1 .

Referring to the hysteresis curve illustrated in Fig. 4, because the elongated elements 200 diffract the incident light by traveling only one-third to one-fourth of the distance to the surface of the substrate, hysteresis is avoided. Instead, starting from the undeformed state, the elongated elements 200 deform toward the substrate and, then, return to the undeformed state along the same voltage versus light intensity curve in each direction of travel. This is in contrast to the prior modulator illustrated in Figs. 1-3 which encounters hysteresis when deforming to into diffracting state. This embodiment allows a continuous selection of the brightness by varying the drive voltage in a continuous manner on the driven elongated elements 200.

Because the end portions of each elongated element 200 are not approximately flat, if light diffracted by the end portions is collected and displayed, the resulting contrast ratio of the display image will tend to be unsatisfactory. Therefore, as explained herein, the present invention provides a light shield for preventing light diffracted from other than the approximately flat center portion 202 of each elongated element 200 from being utilized for forming the display image. In the alternative, the light could be optically manipulated so that it only impinges onto the approximately flat center portion 202. This approach avoids wasting light.

Fig. 14 illustrates top view of an optical display system 400 utilizing the GLV array 402. An illumination arrangement for illuminating the GLV array 402, includes red, green,

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and blue light sources 404R, 404G and 404B, respectively. These light sources can be any convenient source or red, green and blue light and can be semiconductor light emitting devices such as light emitting diodes (LEDs) or semiconductor lasers, or separate diode pumped solid state lasers, or white light with a alternating filters such as a spinning disk with three filters to sequentially pass red, green and blue light. In system 400 light sources 404R, 404G, and 404B are assumed to be sources emitting in a generally symmetrical manner. A dichroic filter group 406 allows light from any one of these light sources to be directed toward a collimating lens 408 propagating generally along a system optical axis z. Dichroic filter groups or prism blocks which cause three light sources of different color to appear to an optical system to emanate from the same point of origin are well known in the optical art, for example, Philips prisms. Accordingly, a detailed description of such dichroic filter groups is not presented herein.

It is also known to use three separate image formation systems, one each for red, green and blue and to then optically combine these images. The system of the present invention could also comprise three display engines which are combined and then scanned to form a composite image.

Because the GLVs are formed using semiconductor processing techniques, it is possible to form three parallel linear arrays that are essentially perfectly aligned one to the other. Three illumination systems, one each for red, green and blue can be configured to impinge their respective color of light onto a single one of the three essentially perfectly aligned GLV linear arrays. In this way, alignment of the composite image is easier than for conventional composite color systems.

One common problem in conventional color display systems is commonly known as color break up. This results from such systems displaying a red frame, a green frame and a blue frame, in any convenient sequence. This technique is known as frame sequential color. If an object passes between the viewer and the displayed image a ghost of that object in one of the colors will appear in the display. Similarly, if the viewer quickly turns their head an artifact of the frame sequential color will appear.

Because the GLV technology can operate at sufficient bandwidth, the system can be made to operate to provide each of the three display colors for each row of the display as it is scanned. The inventors have coined the phrase 'line sequential color' to describe this

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technique. The deleterious artifacts of frame sequential color are not present.

In line sequential color, as the image is scanned each of the three colors is presented to the linear array of the GLV in sequence. In analogous terms, all three colors are presented in what is approximately equal to a single display line in a conventional pixellated display.

The image is formed by scanning a linear array of GLVs. The elongated elements in the linear array are all parallel and perpendicular to the length of the linear array. This avoids any discretly displaying adjacent elements. Thus, there is no pixellation between adjacent display elements such as is present in conventional LCD or CRT displays. Further, because the array is smoothly scanned in a direction perpendicular to the linear array, there can be no pixellation between the display in that direction either. In this way, the image quality is vastly improved over that of conventional display technologies.

Lens 408 is illustrated, for simplicity as a simple "spherical" lens, i.e having equal refractive power in the x and y axes. In Fig. 14, the y axis is in the plane of the illustration and the x axis is perpendicular to the plane of the illustration. The lens 408 collimates light from the light source in both axes. Those familiar with the art to which the present invention pertains, will recognize however, that light output from an endemitting semiconductor laser is more divergent in one transverse (x or y) axis than the other and is astigmatic. Means for collimating the output beam of such a laser and expanding it to a desired size are well-known in the optical art and may require one or more spherical, aspherical, toroidal, or cylindrical (spherical and aspherical) lens elements. Lens 408 is intended to represent a group of one or more such elements.

Divergent light 410 from a symmetrically emitting light source 404 passes through lens 408 and is collimated in both the x and y axes. Bi-axially collimated light 412 is then passed through a cylindrical lens 414. The term "cylindrical" here defining that lens 414 has refractive power in one axis (here, y) only. Those familiar with the optical art will recognize that the surface of the lens 414 may be other than other than circularly cylindrical. The function of lens 414 is to cause bi-axially collimated light 412 passing therethrough to converge (Fig. 14, lines 416) in the y axis, and remain collimated (Fig. 15 lines 418) in the x axis. It should be noted here that lens 414 may also be formed from one or more optical elements as discussed above, and is shown as a single element for

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simplicity.

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GLV array 402 is located at a distance from cylindrical lens 414 of about a focal length (f_1) of the lens. GLV array 402 is aligned in the x axis, on the system optical axis z which corresponds to the optical axis of lenses 408 and 414. The operating surface of the GLV (elongated elements 200) is inclined to the z axis. In Fig. 14, GLV array 402 is inclined as 45 degrees to the axis, which effectively folds the z axis 90 degrees. This selection of inclination of the GLV array 402 is made here for convenience of illustration and should not be considered limiting.

Fig. 15 illustrates a side view of the optical display system illustrated in Fig. 14 taken along the line C-C'. Referring to Fig. 15, light incident on an operating GLV array 402, creates a reflected beam (418) and plus and minus first-order diffracted beams designated by D₊₁ and D₋₁ respectively. These diffracted beams are inclined to the z axis, in the x axis. In the y axis, the diffracted and reflected beams are equally divergent. The diffracted and reflected beams then pass through a magnifying (positive) lens 420 which is separated from GLV array 402 by a focal length f₂ of the lens. Lens 420 is shown as a single element from simplicity, but in practice lens 420 may include two or more elements. Lens 420 provides in effect an eyepiece lens for system 400 and is preferably on of the well-known group of eyepiece lens types, consisting of Huygens, Ramsden, Kellner, Plössel, Abbe, König, and Erfle types.

In the x axis, the reflected beam 422 converges to a focal point on the z axis, at which is placed an elongated stop 423 at about an external telecentric exit pupil P_2 of lens 420. In addition a shield 426 is placed in the area of the pupil P_2 of lens 420 to shield light diffracted from portions of the elongated elements 200 of the GLV array 402 other that light diffracted from the approximately flat center portion 202 of each elongated element. Thus, the shield has a slit that is preferably dimensioned so as to only pass light (D_{+1}, D_{-1}) diffracted from the approximately 25 micron center portion 202 of each elongated element 200.

The Schlieren optics of system 400 can be defined as being a part of a telecentric optical arrangement 428 including GLV array 402 magnifying eyepiece lens 420 and stop 424, with GLV array 402 at about an external object position of lens 420 and stop 424 at about an external (exit) pupil of lens 420. A telecentric system is a system in which the

entrance pupil and/or the exit pupil is located at infinity. It is widely used in optical systems designed for metrology because it tends to reduce measurement or position error caused by slight defocusing of the system. This tendency permits some tolerance in placement of stops and other components of the system in general, and is exploited in certain embodiments of the present invention discussed further hereinbelow.

In the y axis (Fig. 14) divergent reflected light 430 (and diffracted light) is collimated by lens 420. Stop 424 is aligned in the y axis, and intercepts the reflected light. Shield 426 absorbs diffracted light other than light diffracted from the approximately flat center portions 202 of the GLV array 402. Stop 424 may be selected to be absorbing or reflecting. If stop 424 is reflecting, reflected light from is returned to GLV array 420. Diffracted beams D₊₁ and D₋₁, however, being inclined to the z axis and the corresponding incident and reflected beams, converge to focal points about and below (alternatively, on opposite sides of) stop 424 and with the slit of shield 426, thereby passing through exit pupil P₂ without being intercepted.

A scanning mirror 432 is located such as to intercept the diffracted beams and direct them toward a viewer's eye 434. What the viewer sees is a magnified virtual image (at infinity) of GLV array 402. This image is represented in Fig. 5 by line 436, recognizing, of course, that there is no real image here. It will be apparent that the line of the GLV array 402 can represent a row or a column of an image to be displayed. The appropriate remaining rows or columns are then formed as the scan progresses. It is possible that other scanning modes can be used, such as diagonally.

The clongated elements 200 of GLV array 402 are operated to represent, sequentially, different lines of M x N display where M is the number of display elements per line, and N is the number of lines in the display. Each display element 300 includes multiple elongated elements 200, as discussed above. GLV array 402 may be defined generally as representing, a one-dimensional array of light valves, or one row of display elements or pixels. In the magnified virtual image, these pixels will have a relative brightness determined by the operating state of ribbon or ribbons 12 of GLV array 10.

Scanning mirror 432 is moved, angularly, by a drive unit 436 about an axis 438 as illustrated by arrow A (Fig.14), scanning the diffracted beams, and thus the magnified virtual image, linearly, across the field of view of the viewer, as indicated by arrow B, to

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represent sequential lines of the display. Mirror 432 is moved fast enough to cause the scanned virtual image to appear as a two-dimensional image to the viewer. The pivotable scanning mirror 432 can be replace with other types of mirror arrangements such as a rotating faceted polygon mirror.

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Microprocessor-based electronic control circuitry 440 is arranged to accept video data and is coupled to GLV array 402 for using the video data to operate the elongated elements 200 of the GLV array 402 for modulating light diffracted therefrom. The circuitry 440 is arranged such that the light in diffracted beams D₊₁ and D₋₁, is modulated to represent sequential lines of a two-dimensional image representing the video data, as noted above. Control circuitry 440 is also coupled to scanning mirror drive unit 436 to synchronize the display of sequential lines and to provide that sequential frames of the image begin at an extreme of the angular excursion range of scanning mirror 432. The speed of the scanning can be controlled to be sinusoidal, saw toothed or any other convenient speed algorithm. All that is necessary is that the scanning speed be synchronized with the presentation of the data to the GLV array 402.

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Control circuitry 432 is also coupled to light sources 404R, 404G, and 404B for switching the sources sequentially, cooperative with operation of GLV array 402 to provide sequential red, green and blue resolution image of the array, which, together, represent one resolution line of colored two-dimensional image. In this arrangement, the elongated members 200 of each display element 300 are appropriately modulated while each of the light sources 404R, 404G and 404B are sequentially active to provide an appropriate proportion of each of red, green and blue diffracted light for the display element 300 while the corresponding line of the image is displayed to the viewer. This modulation occurs at a rate that is sufficiently high that the viewer perceives an appropriate combined color for each display element 300.

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In an alternate arrangement, light sources 404R, 404G and 404B are activated simultaneously to illuminate GLV array 402 and two additional arrays (not shown) via a dichroic prism block (not shown) placed between lens 420 and the three GLV arrays. Each GLV array would then be arranged to modulate a particular one of the three primary color components red, green, and blue of the image. The dichroic prism block may be of any well-known type for example an above mentioned Phillips prism block, and would in this

case be arranged such that each GLV array appeared to be located at the same distance from, and inclination to, lens 420. In such arrangement, for providing a colored image, light sources 404R, 404G and 404B could be replaced by a single white light source, and dichroic prism block 406 omitted.

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It should be noted here in the Fig. 14, viewer's eye 434 is illustrated in a less than ideal position for properly viewing a magnified virtual image of the display of system 400. Ideally, for viewing such an image, the viewer's eye should be located at about exit pupil P_2 . This is difficult because of mirror 432, which is preferably also located at about this exit pupil. This difficulty can be overcome by optically relaying an image of the exit pupil away from the mirror, to a position at which it is easy to locate a viewers eye, thereby allowing the scanning mirror 432 and the viewer's eye each to be located at about a pupil position.

One means of relaying an image of exit pupil P2 is illustrated in Fig. 16 wherein the

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optical arrangement is shown as optically "unfolded" with scanning mirror 432 represented as a line at exit pupil P₂ of lens 420, that being one preferred position for the scanning mirror 432. In addition, shield 426 is placed in the area of the pupil P₂. Here, pupil-relaying is accomplished by two lenses 442 and 444 of the same focal length, which are spaced apart by a distance equal to twice that focal length to form a unit magnification telecentric relay which places an image P₃ of exit pupil P₂ a focal length of lens 444 away from the lens 444, providing adequate eye-relief from lens 444. Those skilled in the art will recognize, of course, that lenses 442 and 444 may include more than one lens element, and further, that the telecentric relay arrangement illustrated in Fig. 16 is not the only possible optical arrangement for relaying a pupil image.

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Referring now to Fig. 17, (where again the optical system is illustrated as "unfolded" with scanning mirror 432 represented as a line at exit pupil P₂ of lens 420, that being, here also, one preferred position for the scanning mirror 432). Shield 426 is also placed in the area of the pupil P₂. Eyepiece lens 420 may also be used as one element, or group of elements, for projecting a magnified real image of the GLV array 402 on a screen or on a recording medium, such as would be required to provide a projection display or a device for recording or printing an image. Here, a lens (or group of lens elements) 446 is positioned to focus a magnified real image 448 (here, the width) of GLV array 402 at a

finite distance from lens 446. This image could be focussed in a plane 450 which could be a viewing screen for providing a projected (apparent) two-dimensional image, or on a recording medium such a photographic film or paper. In the case of a recorded or printed image, scan mirror 432 could be eliminated, and scanning achieved by moving a recording or printing medium in the scan direction, which, in Fig. 17 is perpendicular to the plane of the illustration, i.e., perpendicular to the orientation of the image. This mechanical scanning motion would, of course, need to be synchronized with image generation by electric circuitry 440 as in system 400.

In an alternate embodiment, rather than utilizing the shield 426 illustrated in Figs. 14-17 to prevent diffracted light from other than the approximately flat center portion 202 (Fig. 12) of each elongated element 200 of the GLV array 402 from reaching the viewer, a reflective element 500 is disposed over the outermost portions of each elongated element 200. A side sectional view of such a reflective element 500 is illustrated in Fig. 18 disposed over a deformed elongated element 200. As can be seen from Fig. 18, the approximately flat center portion 202 (Fig. 12) of the elongated element 200 remains exposed to incident light while the outer portions are covered by the reflective element 500. The reflective element 500 reflects incident light. Therefore, this reflected light does not reach the viewer, nor does it affect the image perceived by the viewer. The reflective element 500 illustrated in Fig. 18 is preferably sufficiently thin that it is in substantially the same plane as the approximately flat center portion 202 of each elongated element 200 (in the undeformed state). The reflective element 500 can also be located in a plane parallel to, spaced apart from, the reflective surface of the elongated elements 200 (in the undeformed state) by a distance d₃ equal to a whole number N of half wavelengths for the expected incident light (i.e. $d_1 = 0$, $\lambda_1/2$, λ_1 , $3\lambda_1/2$, $2\lambda_1$, ..., $N\lambda_1/2$).

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The present invention has been described in terms of specific embodiments incorporating details to facilitate the understanding of the principles of construction and operation of the invention. Such reference herein to specific embodiments and details thereof is not intended to limit the scope of the claims appended hereto. It will be apparent to those skilled in the art that modifications may be made in the embodiment chosen for illustration without departing from the spirit and scope of the invention.

The embodiment described principally above is for forming a display for human viewing. Other types of 'displays' are also contemplated within the present invention. For example, an image could be formed on a rotating drum for transfer to paper in a printing process. In such applications, the light source could also be ultraviolet or infrared. Such an image is not visible to a human but is equally useful.

Specifically, it will be apparent to one of ordinary skill in the art that the device of the present invention could be implemented in several different ways and the apparatus disclosed above is only illustrative of the preferred embodiment of the invention and is in no way a limitation.

Claims:

What is claimed is:

1	1.	A modulator for modulating an incident beam of light having a wavelength,
2	the modulator	comprising:
3	a.	a plurality of elongated elements, each having an approximately flat
4		reflective surface disposed between two ends, the elements arranged parallel
5		to each other and suspended by their respective ends above a substrate; and
6	b.	means for deforming selected ones of the elongated elements toward the
7		substrate thereby entering a deformed state wherein the approximately flat
8		reflective surface of each selected element moves toward the substrate by a
9		grating amplitude without the selected elongated elements contacting the
10		substrate.
1	2.	The modulator according to claim 1 wherein the light is in a range of
2	wavelengths.	
I	3.	The modulator according to claim 1 wherein the light is in a range of visible
2	light waveleng	gths.
1	4.	The modulator according to claim 1 wherein the light is in a range of
2	ultraviolet lig	ht wavelengths.
1	5.	The modulator according to claim 1 wherein the light is in a range of
2	infrared light	wavelengths.

The modulator according to claim 1 wherein the selected ones of the

elongated elements moves approximately one-fourth the wavelength of the light.

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1 7. The modulator according to claim 1 wherein the selected ones of the

- elongated elements move a controllable distance selected to provide a desired brightness of
- 3 modulated light.
- 1 . 8. The modulator according to claim 1 wherein the grating amplitude is
- 2 approximately one-fourth to one-third of a distance between undeformed elongated
- 3 elements and the substrate.
- 1 9. The modulator according to claim 1 wherein the approximately flat reflective
- 2 surface comprises approximately one-third of a length of the corresponding elongated
- 3 element.
- 1 10. The modulator according to claim 1 wherein the elongated elements are
- 2 grouped according to a plurality of display elements arranged in a single linear array
- wherein when the elongated elements corresponding to a display element are undeformed,
- 4 the incident beam of light is reflected by the display element, and when alternate ones of
- 5 elongated elements corresponding to the display element are selectively deformed, the
- 6 incident beam of light is diffracted by the display element.
- 1 11. The modulator according to claim 10 wherein an image from the single
- linear array is scanned to form a two dimensional image.
- 1 12. The modulator according to claim 11 wherein the image from the single
- 2 linear array is scanned sufficiently fast to be integrated into a single nonflickering image by
- 3 a user's eye.
- 1 13. The modulator according to claim 12 wherein each of a plurality of colored
- 2 light sequentially impinges on the modulator as the image is scanned to form an image
- 3 without color break up.

1 14. The modulator according to claim 12 wherein the two dimensional image is 2 not pixellated.

- 1 15. The modulator according to claim 10 wherein a distance of movement of the
- 2 selected ones of the elongated elements determines an intensity for the corresponding
- 3 display element.
- 1 16. The modulator according to claim 10 wherein a ratio of a period of
- 2 reflection to a period of diffraction determines an intensity for the corresponding display
- 3 element.
- 1 17. The modulator according to claim 15 further comprising an optical system
- 2 for forming an image according to a respective intensity formed by each display element.
- 1 18. The modulator according to claim 17 further comprising means for only
- 2 illuminating the approximately flat center portions with the beam of light.
- 1 19. The modulator according to claim 17 further comprising means for
- 2 preventing light diffracted by other than the approximately flat center portions from being
- 3 displayed by the optical system.
- 1 20. The modulator according to claim 19 wherein the means for preventing
- 2 comprises a light shield having a slit for passing light diffracted by the approximately flat
- 3 center portions and for blocking light diffracted by other than the approximately flat center
- 4 portions.
- 1 21. The modulator according to claim 19 where the means for preventing
- 2 comprises a reflective element disposed over the two ends of each elongated element in a
- 3 plane parallel to the reflective surfaces of undeformed elongated elements by distance equal
- 4 to a whole number or zero multiplied by half the wavelength of the incident beam of light.

1 22. The modulator according to claim 10 wherein a medium for printing upon is 2 mechanically scanned past the single linear array to form a printed image thereon.

- 1 23. A modulator for modulating an incident beam of light having a wavelength within a visible range of wavelengths, the modulator comprising:
 - a. a plurality of elongated elements, each having an approximately flat reflective surface disposed between two ends, the elements arranged parallel to each other and suspended by their respective ends above a substrate; and
 - b. means for deforming selected ones of the elongated elements toward the substrate surface thereby entering a deformed state wherein the approximately flat reflective surface of each selected element moves toward the substrate by a grating amplitude of a whole number or zero multiplied by one-half the wavelength of the incident beam of light plus approximately one-fourth the wavelength of the incident beam of light, without the selected elongated elements contacting a surface of the substrate.
- 1 24. The modulator according to claim 23 wherein the grating amplitude is 2 approximately one-fourth to one-third of a distance between undeformed elongated 3 elements and the substrate.
- 1 25. The modulator according to claim 23 wherein the approximately flat 2 reflective surface comprises approximately one-third of a length of the corresponding 3 elongated element.
- The modulator according to claim 23 wherein the elongated elements are grouped according to a plurality of display elements arranged in a single column wherein when the elongated elements corresponding to a display element are undeformed, the incident beam of light is reflected by the display element, and when alternate ones of elongated elements corresponding to the display element are selectively deformed, the incident beam of light is diffracted by the display element.

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1 27. The modulator according to claim 26 wherein a distance of movement of the 2 selected ones of the elongated elements determines an intensity for the corresponding 3 display element. 1 28. The modulator according to claim 26 wherein a ratio of a period of 2 reflection to a period of diffraction determines an intensity for the corresponding display 3 element. 1 29. The modulator according to claim 28 further comprising an optical system 2 for forming an image according to a respective intensity formed by each display element. 1 30. The modulator according to claim 29 further comprising means for 2 preventing light diffracted by other than the approximately flat center portions from being 3 displayed by the optical system. 1 31. The modulator according to claim 30 wherein the means for preventing 2 comprises a light shield having a slit for passing light diffracted by the approximately flat 3 center portions and for blocking light diffracted by other than the approximately flat center 4 portions. The modulator according to claim 30 where the means for preventing 1 32. 2 comprises a reflective element disposed over the two ends of each elongated element in a 3 plane parallel to the reflective surfaces of undeformed elongated elements by distance equal

33. A modulator for modulating an incident beam of light, the modulator

to a whole number or zero multiplied by half the wavelength of the incident beam of light.

2 comprising:

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a. a plurality of elongated elements, each having an approximately flat
reflective surface disposed between two ends, the elements arranged parallel
to each other and suspended by their respective ends above a substrate by a
distance; and

7	b.	means for placing selected ones of the elongated elements in a deformed
8		state wherein the incident beam of light is diffracted by moving the
9		approximately flat reflective surface of the selected ones toward the substrate
10		by a grating amplitude of approximately one-fourth to one-third of the
1 1	•	distance and for returning the selected ones of the elongated elements to an
12		undeformed state wherein the incident beam of light is reflected.
1	34.	The modulator according to claim 33 wherein the approximately flat

- 1 34. The modulator according to claim 33 wherein the approximately flat 2 reflective surface comprises approximately one-third of a length of the corresponding 3 elongated element.
- The modulator according to claim 33 wherein the elongated elements are grouped according to a plurality of display elements arranged in a single column wherein a ratio of a period of reflection to a period of diffraction determines an intensity for the corresponding display element.
- The modulator according to claim 33 wherein the elongated elements are grouped according to a plurality of display elements arranged in a single column and wherein a distance of movement of the selected ones of the elongated elements determines an intensity for the corresponding display element.
- 1 37. The modulator according to claim 35 further comprising an optical system for forming an image according to a respective intensity formed by each display element.
- 1 38. The modulator according to claim 37 further comprising means for
 2 preventing light diffracted by other than the approximately flat center portions from being
 3 displayed by the optical system.

1 2 3 4		The modulator according to claim 38 wherein the means for preventing light shield having a slit for passing light diffracted by the approximately flat ons and for blocking light diffracted by other than the approximately flat center
1	40.	The modulator according to claim 38 where the means for preventing
2	comprises a	reflective element disposed over the two ends of each elongated element in a
3	plane paralle	el to the reflective surfaces of undeformed elongated elements by distance equal
4	to a whole r	number or zero multiplied by half the wavelength of the incident beam of light.
1	41.	A method of modulating an incident beam of light having a wavelength, the
2	method com	prising steps of:
3	a.	causing the beam of light to impinge upon a plurality of elongated elements,
4		each having an approximately flat reflective surface disposed between two
5		ends, the elements arranged parallel to each other and suspended by their
6		respective ends above a substrate by a distance;
7	b.	deforming selected ones of the elongated elements toward the substrate by
8		moving the approximately flat reflective surface of the selected ones toward
9		the substrate by a grating amplitude of approximately one-fourth to one-third
10		of the distance thereby causing the selected ones to be in a deformed state

c. returning the selected ones of the elongated elements to an undeformed state wherein the incident beam of light is reflected.

wherein the incident beam of light is diffracted; and

- 1 42. The method according to claim 41 wherein the grating amplitude is 2 approximately one-fourth to one-third of a distance between undeformed elongated 3 elements and the substrate.
- 1 43. The method according to claim 41 wherein the approximately flat reflective 2 surface comprises approximately one-third of a length of the corresponding elongated 3 element.

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1	44.	The method according to claim 41 wherein the elongated elements are				
2	grouped according to a plurality of display elements arranged in a single column wherein a					
3	ratio of a period of reflection to a period of diffraction determines an intensity for the					
4	corresponding	g display element.				
1	45.	The modulator according to claim 41 wherein the elongated elements are				
2	grouped acco	rding to a plurality of display elements arranged in a single column and				
3	wherein a dis	tance of movement of the selected ones of the elongated elements determines				
4	an intensity f	or the corresponding display element.				
1	46.	The method according to claim 44 further comprising an optical system for				
2	forming an ir	nage according to a respective intensity formed by each display element.				
1	47.	The method according to claim 46 further comprising means for preventing				
2	light diffracte	d by other than the approximately flat center portions from being displayed				
3	by the optical					
1	48.	The method according to claim 47 wherein the means for preventing				
2		ight shield having a slit for passing light diffracted by the approximately flat				
3	center portions and for blocking light diffracted by other than the approximately flat center					
4	portions.	and for erosining right diffractor by other than the approximatery that center				
1	49.	The method according to claim 47 where the means for preventing				
2	comprises a r	eflective element disposed over the two ends of each elongated element in a				
3	plane parallel	to the reflective surfaces of undeformed elongated elements by distance equal				
4	to a whole nu	imber or zero multiplied by half the wavelength of the incident beam of light.				

- 1 50. A method of modulating an incident beam of light having a wavelength, the method comprising steps of:
- a. causing the beam of light to impinge upon a plurality of elongated elements,
 each having an approximately flat reflective surface disposed between two

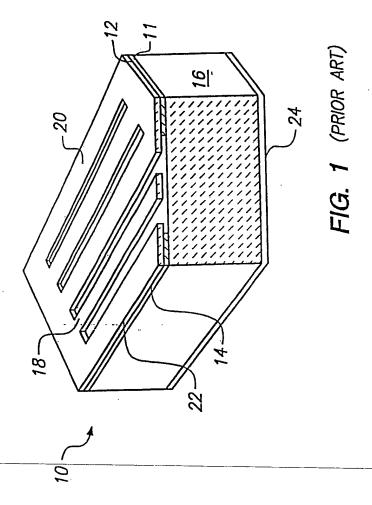
5		ends, the elements arranged parallel to each other and suspended by their
6		respective ends above a substrate; and
7	b	deforming selected ones of the elongated elements toward the substrate
8		surface thereby causing the selected ones to be in a deformed state wherein
9		the approximately flat reflective surface of each selected element is moved
10		toward the substrate by a grating amplitude of a whole number or zero
11		multiplied by one-half the wavelength of the incident beam of light plus

- 12 approximately one-fourth the wavelength of the incident beam of light, 13 without the selected elongated elements contacting a surface of the substrate.
- 1 51. The method according to claim 50 wherein the grating amplitude is 2 approximately one-fourth to one-third of a distance between undeformed elongated 3 elements and the substrate.
- The method according to claim 50 wherein the approximately flat reflective 1 52. 2 surface comprises approximately one-third of a length of the corresponding elongated 3 element.
- 1 53. The method according to claim 50 wherein the elongated elements are 2 grouped according to a plurality of display elements arranged in a single column wherein 3 when the elongated elements corresponding to a display element are undeformed, the 4 incident beam of light is reflected by the display element, and when alternate ones of 5 elongated elements corresponding to the display element are selectively deformed, the 6 incident beam of light is diffracted by the display element.
- 1 54. The modulator according to claim 53 wherein a distance of movement of the 2 selected ones of the elongated elements determines an intensity for the corresponding 3 display element.
- 1 55. The method according to claim 53 wherein a ratio of a period of reflection 2 to a period of diffraction determines an intensity for the corresponding display element.

1	56.	The method according to claim 55 further comprising an optical system for
2	forming an in	nage according to a respective intensity formed by each display element.

- The method according to claim 56 further comprising means for preventing light diffracted by other than the approximately flat center portions from being displayed
- 3 by the optical system.
- The method according to claim 57 wherein the means for preventing comprises a light shield having a slit for passing light diffracted by the approximately flat center portions and for blocking light diffracted by other than the approximately flat center portions.
- The method according to claim 57 where the means for preventing comprises a reflective element disposed over the two ends of each elongated element in a plane parallel to the reflective surfaces of undeformed elongated elements by distance equal to a whole number or zero multiplied by half the wavelength of the incident beam of light.
- 1 60. A method of forming a light modulator on a substrate, the light modulator 2 for modulating an incident beam of light having a wavelength within a visible range of 3 wavelengths, the method comprising steps of:
- a. forming a sacrificial layer on the substrate, wherein the sacrificial layer has a thickness that is approximately equal to the wavelength of the beam of light wherein the sacrificial layer is exposed;
- b. forming at least two elongated elements over the sacrificial layer, each elongated element coupled to the substrate at two of the four locations and
- 9 each elongated element having a reflective surface; and
- 10 c. removing the sacrificial layer.
- 1 61. The method according to claim 60 wherein the thickness is within a range of 2 200 to 2000 nm.

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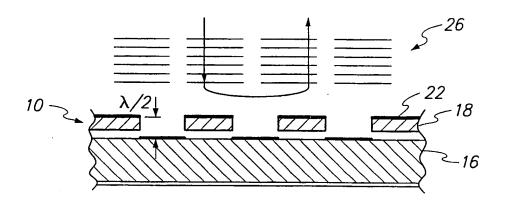


FIG. 2
PRIOR ART

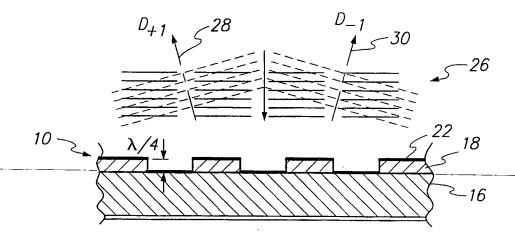


FIG. 3
PRIOR ART

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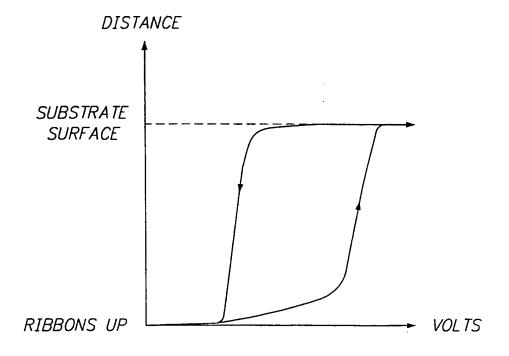
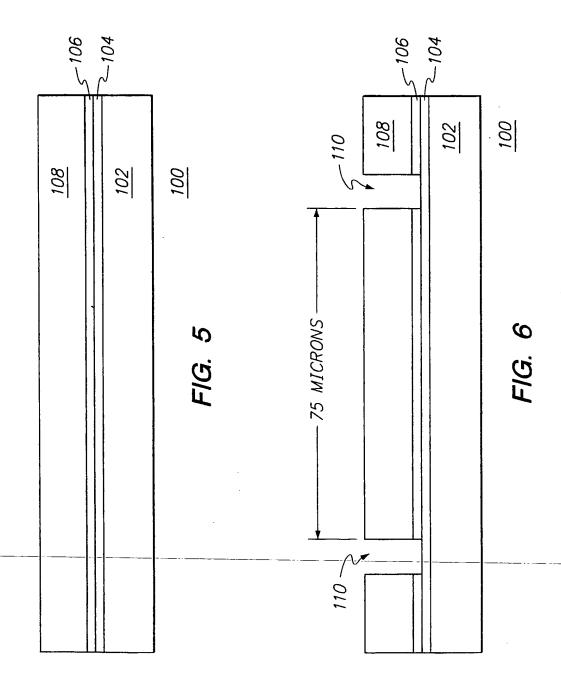
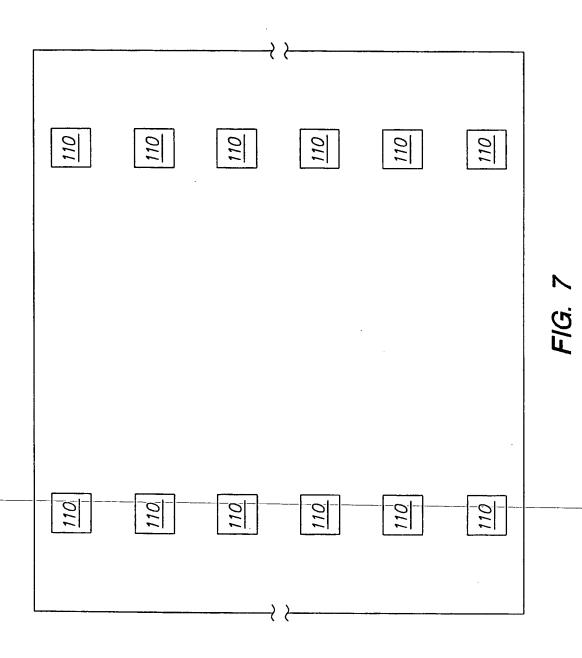
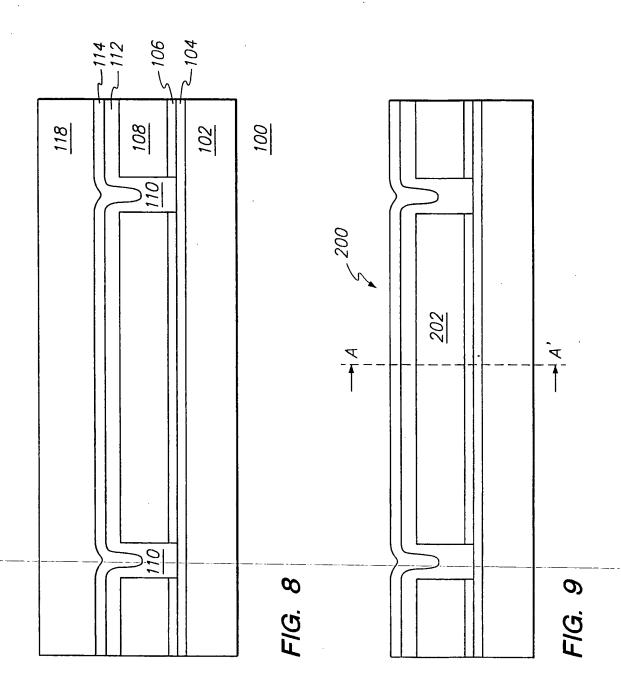


FIG. 4

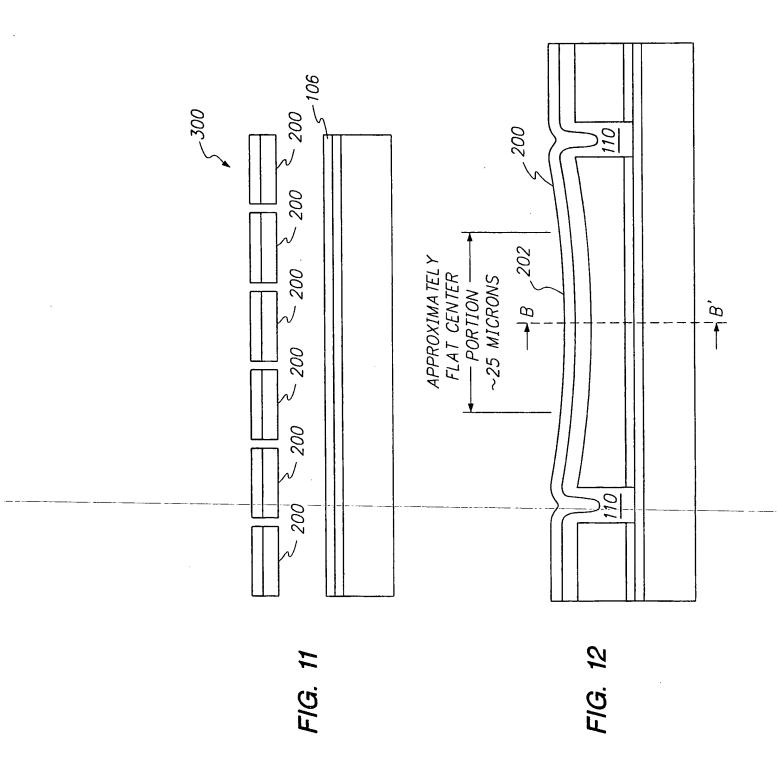


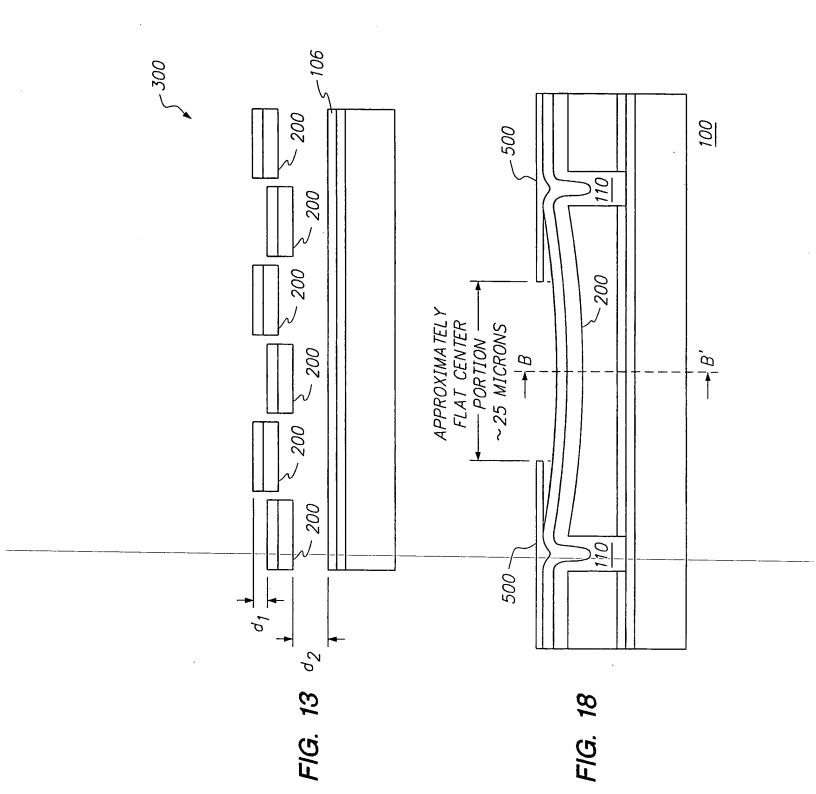


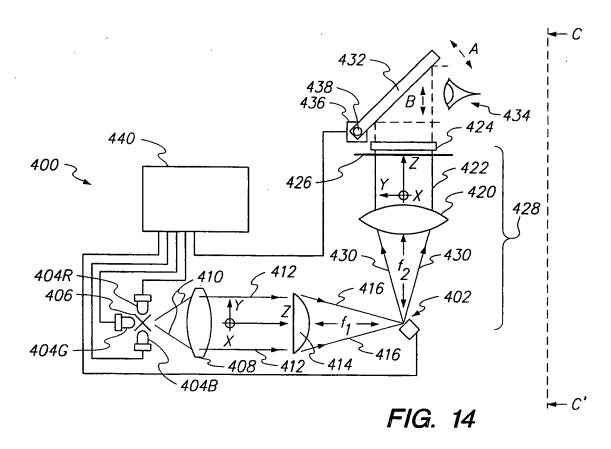


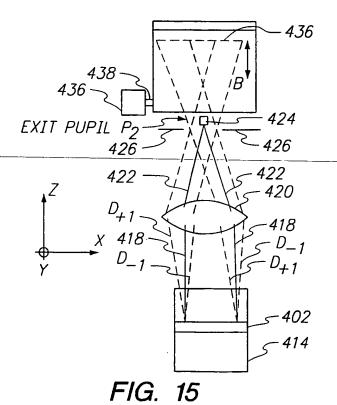
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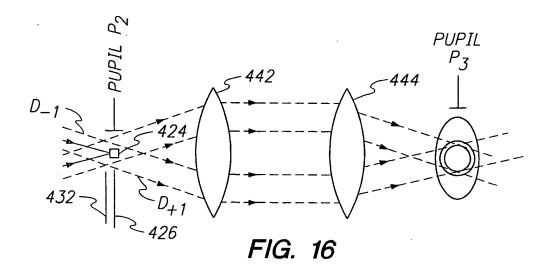








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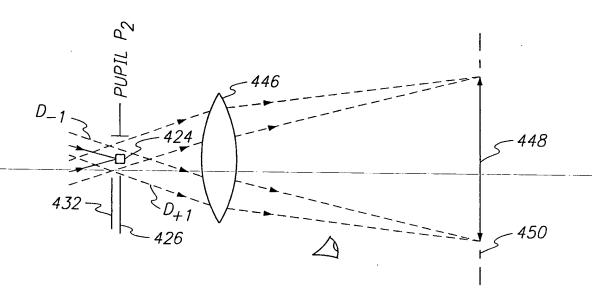


FIG. 17

IN ERNATIONAL SEARCH REPORT

International Application No

fur/US 99/13955 A. CLASSIFICATION OF SUBJECT MATTER IPC 6 G02B26/08 According to International Patent Classification (IPC) or to both national classification and IPC B. FIELDS SEARCHED Minimum documentation searched (classification system followed by classification symbols) IPC 6 G02B Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched Electronic data base consulted during the international search (name of data base and, where practical, search terms used) C. DOCUMENTS CONSIDERED TO BE RELEVANT Category * Citation of document, with indication, where appropriate, of the relevant passages Relevant to claim No. X US 5 757 536 A (RICCO ANTONIO J ET AL) 1-8 26 May 1998 (1998-05-26) Α column 12, line 23 -column 13, line 52; 23,33, figures 1,2,8 41,50,60 HORNBECK L J: "DEFORMABLE-MIRROR SPATIAL X 1-5 LIGHT MODULATORS" SPATIAL LIGHT MODULATORS AND APPLICATIONS III, 7-8 AUGUST 1989, SAN DIEGO, vol. 1150, 7 August 1989 (1989-08-07), pages 86-102, XP000351394 page 86, paragraph 4; figure 1B Α 23,33, 41,50,60 Further documents are listed in the continuation of box C. Patent family members are listed in annex. "Special categories of cited documents: "T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the "A" document defining the general state of the art which is not considered to be of particular relevance invention "E" earlier document but published on or after the international "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled "O" document referring to an oral disclosure, use, exhibition or other means document published prior to the international filing date but later than the pnority date claimed "&" document member of the same patent family Date of the actual completion of the international search Date of mailing of the international search report 7 October 1999 15/10/1999 Name and mailing address of the ISA Authorized officer European Patent Office, P.B. 5818 Patentlaan 2 Nt. – 2280 HV Rijswijk Tel. (+31-70) 340-2040, Tx. 31 651 epo nl, Fax: (+31-70) 340-3016

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Hervé, D

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(74) Agents: HAVERSTOCK, Thomas, B. et al.; Haverstock & Owens LLP, Suite 420, 260 Sheridan Avenue, Palo Alto, CA 94306 (US). (81) Designated States: AL, AM, AU, BB, BG, BR, CA, CN, CZ, EE, ES, FI, GE, HU, IS, JP, KG, KP, KR, LK, LR, LT, LV, MD, MG, MK, MN, MX, NO, NZ, PL, RO, SG, SI, SK, TR, TT, UA, UZ, VN, ARIPO patent (GH, GM, KE, LS, MW, SD, SL, SZ, UG, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, GW, ML, MR, NE, SN, TD, TG).

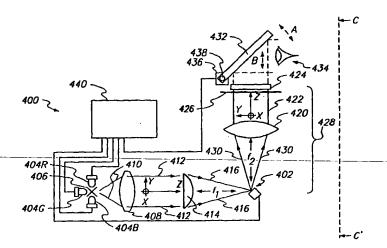
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With amended claims and statement,

Date of publication of the amended claims and statement:

10 February 2000 (10.02.00)

(54) Title: METHOD AND APPARATUS FOR MODULATING AN INCIDENT LIGHT BEAM FOR FORMING A TWO-DIMENSIONAL IMAGE



(57) Abstract

An apparatus and method for modulating an incident light beam for forming a two-dimensional projection image. The apparatus includes a plurality of elongated elements each having a reflective surface. These are suspended parallel to each other above a substrate with their respective ends supported, forming a column of adjacent reflecting surfaces grouped according to display elements. Alternate ones of each group are deformable by applying a voltage with respect to the substrate. An approximately flat center section of each deformed element is substantially parallel to and a predetermined distance from a center section of each undeformed element. A light beam incident to the column of adjacent reflecting surfaces is reflected from a group of elongated elements when the alternate ones are undeformed and diffracted when the alternate ones are deformed. A distance of movement is controlled or a ratio of between reflection and diffraction periods determines a display intensity for the corresponding display element.

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AMENDED CLAIMS

[received by the International Bureau on 13 December 1999 (13.12.99); original claims 1, 23, 33, 41, 50 and 60 amended; new claims 62-77 added; remaining claims unchanged (16 pages)]

1	1.	A modulator for modulating an incident beam of light having a wavelength,
2	the modulator	comprising:
3	a. .	a plurality of elongated elements, each having an approximately flat
4		reflective surface disposed between two ends, each elongated element having
5		an approximately constant cross-section between the two ends, the elements
6		arranged parallel to each other and suspended by their respective ends above
7		a substrate; and
8	b.	means for deforming selected ones of the elongated elements toward the
9		substrate thereby entering a deformed state wherein the approximately flat
10		reflective surface of each selected element moves toward the substrate by a
11		grating amplitude without the selected elongated elements contacting the
12		substrate.
		•
1	2. .	The modulator according to claim 1 wherein the light is in a range of
2	wavelengths	
1	3.	The modulator according to claim 1 wherein the light is in a range of visible
2	light wavele	ngths.
1	4.	The modulator according to claim 1 wherein the light is in a range of
2	ultraviolet li	ght wavelengths.
1	5	The modulator according to claim 1 wherein the light is in a range of
2	infrared ligh	nt wavelengths.
1	6.	The modulator according to claim 1 wherein the selected ones of the
2	elongated e	lements moves approximately one-fourth the wavelength of the light.

7. The modulator according to claim 1 wherein the selected ones of the elongated elements move a controllable distance selected to provide a desired brightness of

- 1 8. The modulator according to claim 1 wherein the grating amplitude is
- 2 approximately one-fourth to one-third of a distance between undeformed elongated
- 3 elements and the substrate.

modulated light.

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- 1 9. The modulator according to claim 1 wherein the approximately flat
- 2 reflective surface comprises approximately one-third of a length of the corresponding
- 3 elongated element.
- 1 10. The modulator according to claim 1 wherein the elongated elements are
- 2 grouped according to a plurality of display elements arranged in a single linear array
- wherein when the elongated elements corresponding to a display element are undeformed,
- 4 the incident beam of light is reflected by the display element, and when alternate ones of
- 5 elongated elements corresponding to the display element are selectively deformed, the
- 6 incident beam of light is diffracted by the display element.
- 1 11. The modulator according to claim 10 wherein an image from the single
- 2 linear array is scanned to form a two dimensional image.
- 1 12. The modulator according to claim 11 wherein the image from the single
- 2 linear array is scanned sufficiently fast to be integrated into a single nonflickering image
- 3 by a user's eye.
- 1 13. The modulator according to claim 12 wherein each of a plurality of colored
- 2 light sequentially impinges on the modulator as the image is scanned to form an image
- 3 without color break up.

1 14. The modulator according to claim 12 wherein the two dimensional image is

- 2 not pixellated.
- 1 15. The modulator according to claim 10 wherein a distance of movement of the
- 2 selected ones of the elongated elements determines an intensity for the corresponding
- 3 display element.
- 1 16. The modulator according to claim 10 wherein a ratio of a period of
- 2 reflection to a period of diffraction determines an intensity for the corresponding display
- 3 element.
- 1 17. The modulator according to claim 15 further comprising an optical system
- for forming an image according to a respective intensity formed by each display element.
- 1 18. The modulator according to claim 17 further comprising means for only
- 2 illuminating the approximately flat center portions with the beam of light.
- 1 19. The modulator according to claim 17 further comprising means for
- 2 preventing light diffracted by other than the approximately flat center portions from being
- 3 displayed by the optical system.
- 1 20. The modulator according to claim 19 wherein the means for preventing
- comprises a light shield having a slit for passing light diffracted by the approximately flat
- 3 center portions and for blocking light diffracted by other than the approximately flat center
- 4 portions.
- 1 21. The modulator according to claim 19 where the means for preventing
- comprises a reflective element disposed over the two ends of each elongated element in a
- 3 plane parallel to the reflective surfaces of undeformed elongated elements by distance
- 4 equal to a whole number or zero multiplied by half the wavelength of the incident beam of
- 5 light.

1	22.	The modulator according to claim 10 wherein a medium for printing upon is
2	mechanically	scanned past the single linear array to form a printed image thereon.

- 1 23. A modulator for modulating an incident beam of light having a wavelength 2 within a visible range of wavelengths, the modulator comprising:
 - a. a plurality of elongated elements, each having an approximately flat
 reflective surface disposed between two ends, each elongated element having
 an approximately constant cross-section between the two ends, the elements
 arranged parallel to each other and suspended by their respective ends above
 a substrate; and
 - b. means for deforming selected ones of the elongated elements toward the substrate surface thereby entering a deformed state wherein the approximately flat reflective surface of each selected element moves toward the substrate by a grating amplitude of a whole number or zero multiplied by one-half the wavelength of the incident beam of light plus approximately one-fourth the wavelength of the incident beam of light, without the selected elongated elements contacting a surface of the substrate.
 - The modulator according to claim 23 wherein the grating amplitude is approximately one-fourth to one-third of a distance between undeformed elongated elements and the substrate.
 - 1 25. The modulator according to claim 23 wherein the approximately flat 2 reflective surface comprises approximately one-third of a length of the corresponding 3 elongated element.
 - The modulator according to claim 23 wherein the elongated elements are grouped according to a plurality of display elements arranged in a single column wherein when the elongated elements corresponding to a display element are undeformed, the incident beam of light is reflected by the display element, and when alternate ones of elongated elements corresponding to the display element are selectively deformed, the

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6 incident beam of light is diffracted by the display element.

- 1 27. The modulator according to claim 26 wherein a distance of movement of the
- 2 selected ones of the elongated elements determines an intensity for the corresponding
- 3 display element.
- 1 28. The modulator according to claim 26 wherein a ratio of a period of
- 2 reflection to a period of diffraction determines an intensity for the corresponding display
- 3 element.
- 1 29. The modulator according to claim 28 further comprising an optical system
- for forming an image according to a respective intensity formed by each display element.
- 1 30. The modulator according to claim 29 further comprising means for
- 2 preventing light diffracted by other than the approximately flat center portions from being
- 3 displayed by the optical system.
- The modulator according to claim 30 wherein the means for preventing
- 2 comprises a light shield having a slit for passing light diffracted by the approximately flat
- center portions and for blocking light diffracted by other than the approximately flav center
- 4 portions.
- 1 32. The modulator according to claim 30 where the means for preventing:
- 2 comprises a reflective element disposed over the two ends of each elongated element in a
- 3 plane parallel to the reflective surfaces of undeformed elongated elements by distance
- 4——equal-to-a whole number or zero multiplied by half the wavelength of the incident beam of
- 5 light.
- 1 33. A modulator for modulating an incident beam of light, the modulator
- 2 comprising:
- a. a plurality of elongated elements, each having an approximately flat

4	reflective surface disposed between two ends, each elongated element having
5	an approximately constant cross-section between the two ends, the elements
6	arranged parallel to each other and suspended by their respective ends above
7	a substrate by a distance; and
8	b. means for placing selected ones of the elongated elements in a deformed
9	state wherein the incident beam of light is diffracted by moving the
10	approximately flat reflective surface of the selected ones toward the
11	substrate by a grating amplitude of approximately one-fourth to one-third of
12	the distance and for returning the selected ones of the elongated elements to
13	an undeformed state wherein the incident beam of light is reflected.
1	34. The modulator according to claim 33 wherein the approximately flat
2	reflective surface comprises approximately one-third of a length of the corresponding
3	elongated element.
1	35. The modulator according to claim 33 wherein the elongated elements are
2	grouped according to a plurality of display elements arranged in a single column wherein a
3	ratio of a period of reflection to a period of diffraction determines an intensity for the
4	corresponding display element.
1	36. The modulator according to claim 33 wherein the elongated elements are
2	grouped according to a plurality of display elements arranged in a single column and
3	wherein a distance of movement of the selected ones of the elongated elements determines
4	an intensity for the corresponding display element.
i	37. The modulator according to claim 35 further comprising an optical system
2	for forming an image according to a respective intensity formed by each display element.
1	38. The modulator according to claim 37 further comprising means for
2	preventing light diffracted by other than the approximately flat center portions from being
3	displayed by the optical system.

1	39.	The modulator according to claim 38 wherein the means for preventing
2	comprises a	light shield having a slit for passing light diffracted by the approximately flat
3	center portio	ons and for blocking light diffracted by other than the approximately flat center
4	portions.	
1	40.	The modulator according to claim 38 where the means for preventing
2	comprises a	reflective element disposed over the two ends of each elongated element in a
3	plane paralle	el to the reflective surfaces of undeformed elongated elements by distance
4	equal to a v	whole number or zero multiplied by half the wavelength of the incident beam of
5	light.	
1	41.	A method of modulating an incident beam of light having a wavelength, the
2	method con	nprising steps of:
3	a.	causing the beam of light to impinge upon a plurality of elongated elements,
4		each having an approximately flat reflective surface disposed between two
5		ends, each elongated element having an approximately constant cross-section
6		between the two ends, the elements arranged parallel to each other and
7		suspended by their respective ends above a substrate by a distance;
8	b.	deforming selected ones of the elongated elements toward the substrate by
9		moving the approximately flat reflective surface of the selected ones loward
10		the substrate by a grating amplitude of approximately one-fourth to one-third
11		of the distance thereby causing the selected ones to be in a deformed state
12		wherein the incident beam of light is diffracted; and
13	c.	returning the selected ones of the elongated elements to an undeformed state
14		wherein the incident beam of light is reflected.
1	42.	The method according to claim 41 wherein the grating amplitude is
2	approxima	tely one-fourth to one-third of a distance between undeformed elongated
3	elements a	and the substrate.

The method according to claim 41 wherein the approximately flat reflective

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surface comprises approximately one-third of a length of the corresponding elongated element.

- 1 44. The method according to claim 41 wherein the elongated elements are
- 2 grouped according to a plurality of display elements arranged in a single column wherein a
- ratio of a period of reflection to a period of diffraction determines an intensity for the
- 4 corresponding display element.
- 1 45. The modulator according to claim 41 wherein the elongated elements are
- 2 grouped according to a plurality of display elements arranged in a single column and
- wherein a distance of movement of the selected ones of the elongated elements determines
- 4 an intensity for the corresponding display element.
- 1 46. The method according to claim 44 further comprising an optical system for
- 2 forming an image according to a respective intensity formed by each display element.
- 1 47. The method according to claim 46 further comprising means for preventing
- 2 light diffracted by other than the approximately flat center portions from being displayed
- 3 by the optical system.
- 1 48. The method according to claim 47 wherein the means for preventing
- 2 comprises a light shield having a slit for passing light diffracted by the approximately flat
- 3 center portions and for blocking light diffracted by other than the approximately flat center
- 4 portions.
- 1—49. The method according to claim 47 where the means for preventing
- 2 comprises a reflective element disposed over the two ends of each elongated element in a
- 3 plane parallel to the reflective surfaces of undeformed elongated elements by distance
- equal to a whole number or zero multiplied by half the wavelength of the incident beam of
- 5 light.

1	50.	A method of modulating an incident beam of light having a wavelength, the
2	method com	prising steps of:
3 .	a.	causing the beam of light to impinge upon a plurality of elongated elements,
4		each having an approximately flat reflective surface disposed between two
5		ends, each elongated element having an approximately constant cross-section
6		between the two ends, the elements arranged parallel to each other and
7		suspended by their respective ends above a substrate; and
8	b.	deforming selected ones of the elongated elements toward the substrate
9		surface thereby causing the selected ones to be in a deformed state wherein
10		the approximately flat reflective surface of each selected element is moved
11		toward the substrate by a grating amplitude of a whole number or zero
12		multiplied by one-half the wavelength of the incident beam of light plus
13		approximately one-fourth the wavelength of the incident beam of light,
14		without the selected elongated elements contacting a surface of the substrate.
1	51.	The method according to claim 50 wherein the grating amplitude is
2	approximat	ely one-fourth to one-third of a distance between undeformed elongated
3	elements as	nd the substrate.
1	52.	The method according to claim 50 wherein the approximately flat reflective
2	surface con	nprises approximately one-third of a length of the corresponding elongated
3	element.	
1	53.	The method according to claim 50 wherein the elongated elements are
2	grouped a	ecording to a plurality of display elements arranged in a single column wherein
3_		elongated elements corresponding to a display element are undeformed, the
4	incident b	eam of light is reflected by the display element, and when alternate ones of
5	elongated	elements corresponding to the display element are selectively deformed, the
6		eam of light is diffracted by the display element.
1	54.	The modulator according to claim 53 wherein a distance of movement of the

2 selected ones of the elongated elements determines an intensity for the corresponding

3 display elem	ment.
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- 1 55. The method according to claim 53 wherein a ratio of a period of reflection
- to a period of diffraction determines an intensity for the corresponding display element.
- 1 56. The method according to claim 55 further comprising an optical system for
- forming an image according to a respective intensity formed by each display element.
- 1 57. The method according to claim 56 further comprising means for preventing
- 2 light diffracted by other than the approximately flat center portions from being displayed
- 3 by the optical system.
- 1 58. The method according to claim 57 wherein the means for preventing
- 2 comprises a light shield having a slit for passing light diffracted by the approximately flat
- 3 center portions and for blocking light diffracted by other than the approximately flat center
- 4 portions.
- 1 59. The method according to claim 57 where the means for preventing
- 2 comprises a reflective element disposed over the two ends of each elongated element in a
- plane parallel to the reflective surfaces of undeformed elongated elements by distance
- 4 equal to a whole number or zero multiplied by half the wavelength of the incident beam of
- 5 light.
- 1 60. A method of forming a light modulator on a substrate, the light modulator
- 2 for modulating an incident beam of light having a wavelength within a visible range of
- wavelengths, the method comprising steps of:
- a. forming a sacrificial layer on the substrate, wherein the sacrificial layer has
- a thickness that is approximately equal to the wavelength of the beam of
- 6 light wherein the sacrificial layer is exposed;
- b. forming at least two elongated elements over the sacrificial layer, each

8		elongated element coupled to the substrate at two of four locations and each
9		elongated element having a reflective surface; and
10	c.	removing the sacrificial layer.
1	61.	The method according to claim 60 wherein the thickness is within a range of
2	200 to 2000	nm.
1	62.	The method according to claim 60 wherein the two of the four locations are
2	proximate t	to ends of each of the at least two elongated elements.
1	63.	The modulator according to claim 1 wherein the means for deforming uses
2	an applied	voltage such that the deformed state follows a reversible function of the applied
3	voltage.	
1	64.	The modulator according to claim 23 wherein the means for deforming uses
2	an applied	voltage such that the deformed state follows a reversible function of the applied
3	voltage.	
1	65.	The modulator according to claim 33 wherein the means for placing uses an
2	applied vo	ltage such that the deformed state follows a reversible function of the applied
3	voltage.	
1	66.	The method according to claim 41 wherein the step of deforming use: an
2	applied vo	stage such that the approximately flat reflective surface follows a reversible
3	function o	f the applied voltage.
1	67.	The method according to claim 50 wherein the step of deforming uses an
2	applied vo	oltage such that the deformed state follows a reversible function of the applied
3	voltage.	
1	68.	A modulator for modulating an incident beam of light having a wavelength,

2	the modulator	comprising:
3	a.	a plurality of elongated elements, each having an approximately flat
4		reflective surface disposed between two ends, the elements arranged parallel
5		to each other and suspended by their respective ends by integrally formed
6		supports above a substrate; and
7	b.	means for deforming selected ones of the elongated elements toward the
8		substrate thereby entering a deformed state wherein the approximately flut
9		reflective surface of each selected element moves toward the substrate by a
10		grating amplitude without the selected elongated elements contacting the
11		substrate.
1	69.	A modulator for modulating an incident beam of light having a wavelength
2	within a visi	ble range of wavelengths, the modulator comprising:
3	a.	a plurality of elongated elements, each having an approximately flat
4		reflective surface disposed between two ends, the elements arranged parallel
5		to each other and suspended by their respective ends by integrally formed
6		supports above a substrate; and
7	ъ.	means for deforming selected ones of the elongated elements toward the
8		substrate surface thereby entering a deformed state wherein the
9		approximately flat reflective surface of each selected element moves toward
10		the substrate by a grating amplitude of a whole number or zero multiplied
11		by one-half the wavelength of the incident beam of light plus approximately
12		one-fourth the wavelength of the incident beam of light, without the selected
13		elongated elements contacting a surface of the substrate.
— <u>1</u> —	7 0	A modulator for modulating an incident beam of light, the modulator
2	comprising	:
3	a.	a plurality of elongated elements, each having an approximately flat
4		reflective surface disposed between two ends, the elements arranged parallel
5		to each other and suspended by their respective ends by integrally formed
6		supports above a substrate by a distance; and

7	b.	means for placing selected ones of the elongated elements in a deformed
8		state wherein the incident beam of light is diffracted by moving the
9 .		approximately flat reflective surface of the selected ones toward the
10		substrate by a grating amplitude of approximately one-fourth to one-third of
11		the distance and for returning the selected ones of the elongated elements to
12		an undeformed state wherein the incident beam of light is reflected.
1	71.	A method of modulating an incident beam of light having a wavelength, the
2		prising steps of:
3	a.	causing the beam of light to impinge upon a plurality of elongated elements,
4		each having an approximately flat reflective surface disposed between two
5		ends, the elements arranged parallel to each other and suspended by their
6		respective ends by integrally formed supports above a substrate by a
7		distance;
8	ъ.	deforming selected ones of the elongated elements toward the substrate by
9		moving the approximately flat reflective surface of the selected ones toward
10		the substrate by a grating amplitude of approximately one-fourth to one-third
11		of the distance thereby causing the selected ones to be in a deformed state
12		wherein the incident beam of light is diffracted; and
13	c.	returning the selected ones of the elongated elements to an undeformed state
14		wherein the incident beam of light is reflected.
1	72.	A method of modulating an incident beam of light having a wavelength, the
2	method cor	mprising steps of:
3	a.	causing the beam of light to impinge upon a plurality of elongated elements
4_		each having an approximately flat reflective surface disposed between two
5		ends, the elements arranged parallel to each other and suspended by their
6		respective ends by integrally formed supports above a substrate; and
7	b.	deforming selected ones of the elongated elements toward the substrate
8		surface thereby causing the selected ones to be in a deformed state wherein
9		the approximately flat reflective surface of each selected element is moved

10		toward the substrate by a grating amplitude of a whole number of zero
11		multiplied by one-half the wavelength of the incident beam of light plus
12		approximately one-fourth the wavelength of the incident beam of light,
13		without the selected elongated elements contacting a surface of the substrate.
•	7 2	A modulator for modulating an incident beam of light having a wavelength,
1	73.	r comprising:
2		a plurality of elongated elements, each having an approximately flat
3	a.	
4		reflective surface disposed between two ends, the elements arranged parallel
5		to each other and suspended by their respective ends above a substrate and
6		having no framing superstructure; and
7	ъ.	means for deforming selected ones of the elongated elements toward the
8		substrate thereby entering a deformed state wherein the approximately flat
9		reflective surface of each selected element moves toward the substrate by a
10		grating amplitude without the selected elongated elements contacting the
11		substrate.
1	74 .	A modulator for modulating an incident beam of light having a wavelength
2		ible range of wavelengths, the modulator comprising:
3	8.	a plurality of elongated elements, each having an approximately flat
4		reflective surface disposed between two ends, the elements arranged parallel
5		to each other and suspended by their respective ends above a substrate and
6		having no framing superstructure; and
7	ъ.	means for deforming selected ones of the elongated elements toward the
8		substrate surface thereby entering a deformed state wherein the
9-		approximately flat reflective surface of each selected element moves toward
10		the substrate by a grating amplitude of a whole number or zero multiplied
11		by one-half the wavelength of the incident beam of light plus approximately
12		one-fourth the wavelength of the incident beam of light, without the selected
13		elongated elements contacting a surface of the substrate.

1	75.	A modulator for modulating an incident beam of light, the modulator
2	comprising:	
3	a.	a plurality of elongated elements, each having an approximately flat
4		reflective surface disposed between two ends, the elements arranged parallel
5		to each other and suspended by their respective ends above a substrate by a
6		distance and having no framing superstructure; and
7	ъ.	means for placing selected ones of the elongated elements in a deformed
8		state wherein the incident beam of light is diffracted by moving the
9		approximately flat reflective surface of the selected ones toward the
10		substrate by a grating amplitude of approximately one-fourth to one-third of
11		the distance and for returning the selected ones of the elongated elements to
12		an undeformed state wherein the incident beam of light is reflected.
1	76 .	A method of modulating an incident beam of light having a wavelengtl, the
2	method comp	prising steps of:
3	a .	causing the beam of light to impinge upon a plurality of elongated elements,
4		each having an approximately flat reflective surface disposed between two
5		ends, the elements arranged parallel to each other and suspended by their
6		respective ends above a substrate by a distance and having no framing
7		superstructure;
8	ъ.	deforming selected ones of the elongated elements toward the substrate by
9	-	moving the approximately flat reflective surface of the selected ones toward
10		the substrate by a grating amplitude of approximately one-fourth to one-third
11		of the distance thereby causing the selected ones to be in a deformed state
12		wherein the incident beam of light is diffracted; and
13	c.	returning the selected ones of the elongated elements to an undeformed state
14		wherein the incident beam of light is reflected.

- 1 77. A method of modulating an incident beam of light having a wavelength, the method comprising steps of:
- a. causing the beam of light to impinge upon a plurality of elongated elements,

4		each having an approximately flat reflective surface disposed between two
5		ends, the elements arranged parallel to each other and suspended by their
6 -		respective ends above a substrate and having no framing superstructure; and
7	b.	deforming selected ones of the elongated elements toward the substrate
8		surface thereby causing the selected ones to be in a deformed state wherein
9		the approximately flat reflective surface of each selected element is moved
10		toward the substrate by a grating amplitude of a whole number or zero
11		multiplied by one-half the wavelength of the incident beam of light plus
12		approximately one-fourth the wavelength of the incident beam of light,
13		without the selected elongated elements contacting a surface of the substrate.

STATEMENT UNDER ARTICLE 19

Claims 1, 23, 33, 41, and 50 claim a light modulator including a plurality of elongated elements suspended over a substrate and means for deforming selected ones of the elongated members such that the elongated members do not contact a substrate below the elongated members. The Applicants have amended Claims 1, 23, 33, 41, and 50 to clarify that the elongated elements of Claims 1, 23, 33, 41, and 50 have an approximately constant cross-section between ends of the elongated members. None of the cited references teaches or suggests the claim limitations as amended. Accordingly, the Applicants believe that Claims 1, 23, 33, 41, and 50 and the Dependent Claims 2-22, 24-32, 34-40, and 51-59 are novel and include an inventive step.

Claim 60 claims a method of forming a light modulator. On line 8 of Claim 60 the expression "at two of the four locations" lacks antecedent basis. Accordingly, the Applicants have amended Claim 60 to "at two of four locations" so that Claim 60 has the correct antecedent basis. New Claim 62 is dependent on the Independent Claim 60. Claim 62 adds the limitations that the two locations are proximate to ends of the elongated members.

New Claims 63-67 add an additional limitation to Independent Claims 1, 23, 33, 41, and 50, respectively. Accordingly, Claims 63-67 are novel and include an inventive step at least because Claims 63-67 depend on allowable base claims.

New Claims 68-72 are copies of Original Claims 1, 23, 33, 41, and 50 with the further limitation that the elongated elements are suspended above the substrate by integrally formed supports. None of the cited references teaches or suggests the claim limitations of Claims 68-72. Accordingly, the Applicants believe that Claims 68-72 are novel and include an inventive step.

New Claims 73-77 are copies of Original Claims 1, 23, 33, 41, and 50 with the further limitation that the elongated elements, which are suspended above the substrate, have no framing structure. None of the cited references teaches or suggests the claim—limitations of Claims 73-77. Accordingly, the Applicants believe that Claims 73-77 are novel and include an inventive step.